

**Search Notes**

Application No.

10/708,210

Examiner

Granvill D Lee, Jr

Applicant(s)

LAI ET AL.

Art Unit

2825

**SEARCHED**

Class	Subclass	Date	Examiner
438	202,917	9/28/2004	GL
438	301-308	9/28/2004	GL
438	368-373	9/28/2004	GL
438	473,480	9/28/2004	GL
438	510-515	9/28/2004	GL
438	518-527	9/28/2004	GL
257	390	9/28/2004	GL
257	610	9/28/2004	GL

**INTERFERENCE SEARCHED**

Class	Subclass	Date	Examiner
438	308,369	9/28/2004	GL
438	373,473	9/28/2004	GL
438	506-527	9/28/2004	GL
257/390,610			

**SEARCH NOTES  
(INCLUDING SEARCH STRATEGY)**

	DATE	EXMR
shallow/deep dopant, liner/mask layer, second ion implant. and concentration	9/28/2004	GL